



# Electro Deionization: EDI Systems.

Electro Pure EDI, Inc.: *High technology water* <sup>tm</sup>

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## : EDI Electro Deionization

1. EDI Pure Water System  
가?
2. EDI 가?
3. EDI 가 가?
4. EDI 가?
5. EDI ?



# EDI

## 1. EDI

- EDI 가
- EDI

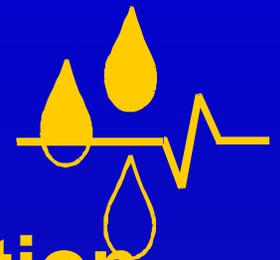
## 2. EDI

- EDI



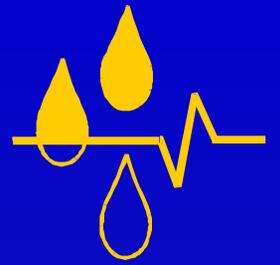
# EDI

- ◇ 2 : / ED
- ◇ 1950 -1960 :
- ◇ 1960 : Ionics & GE “Filled cell ED”
- ◇ 1977: SRI Electropure EDI prototype
- ◇ 1984: Electropure가 EDI
- ◇ 1985: Millipore 가 EDI
- ◇ 1983-87: EDI
- ◇ 1988: EDI (Electropure)
- ◇ 1993: Ionpure 가 USF
- ◇ 1996: Glegg 가 E-cell<sup>tm</sup>
- ◇ 1998: EDI
- ◇ 2000-2001: DI  
EDI 가 DI



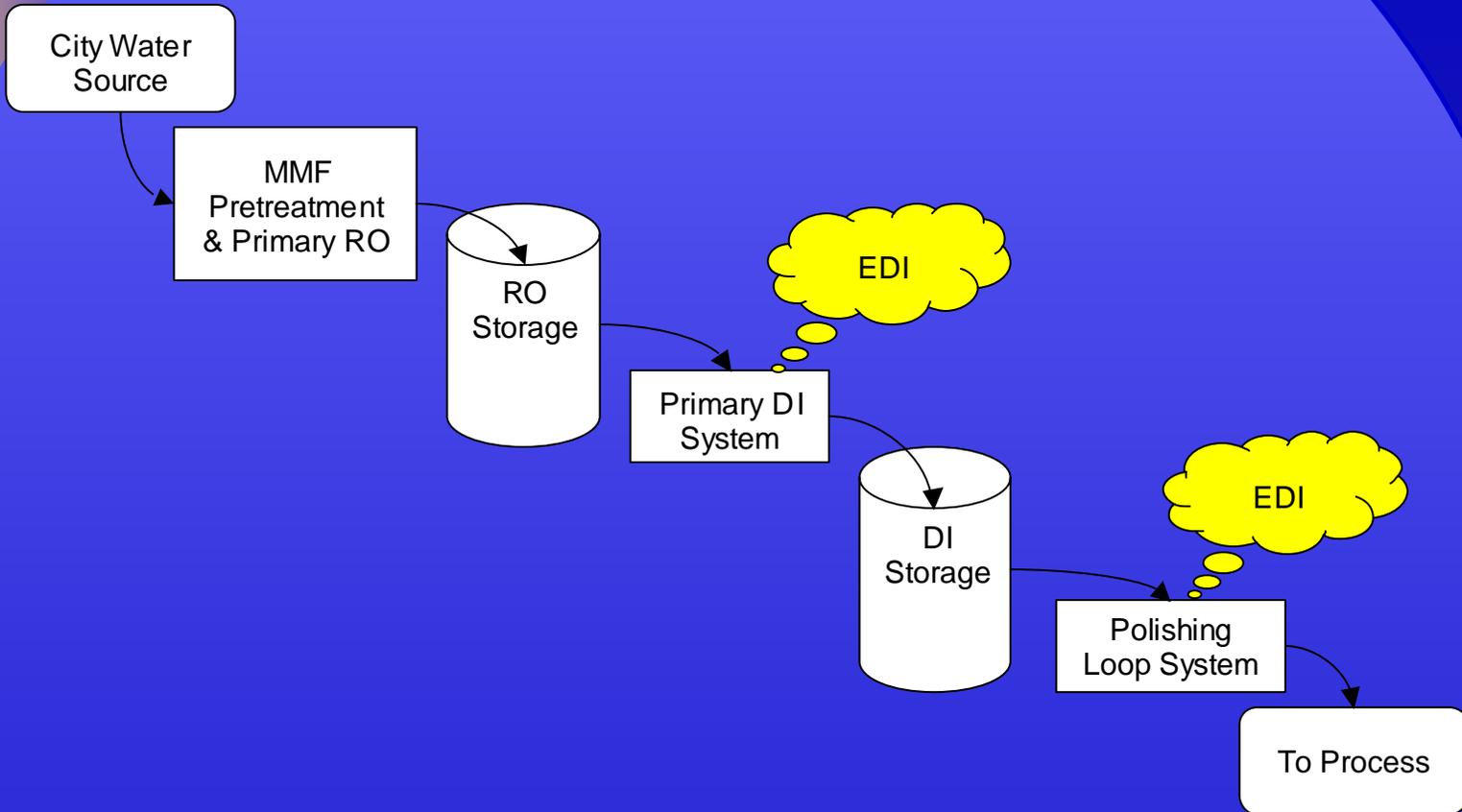
# Introduction: EDI Electro Deionization

1. EDI      Pure Water System  
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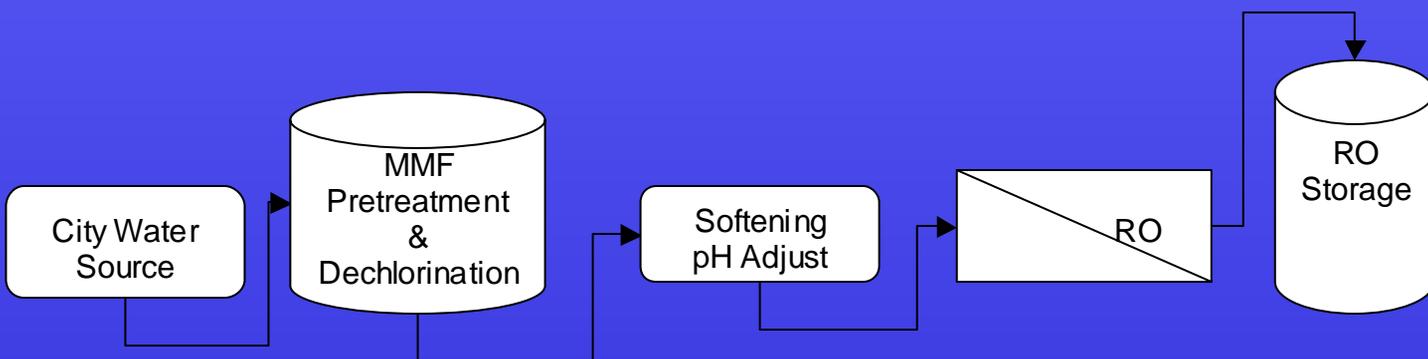
全

# EDI





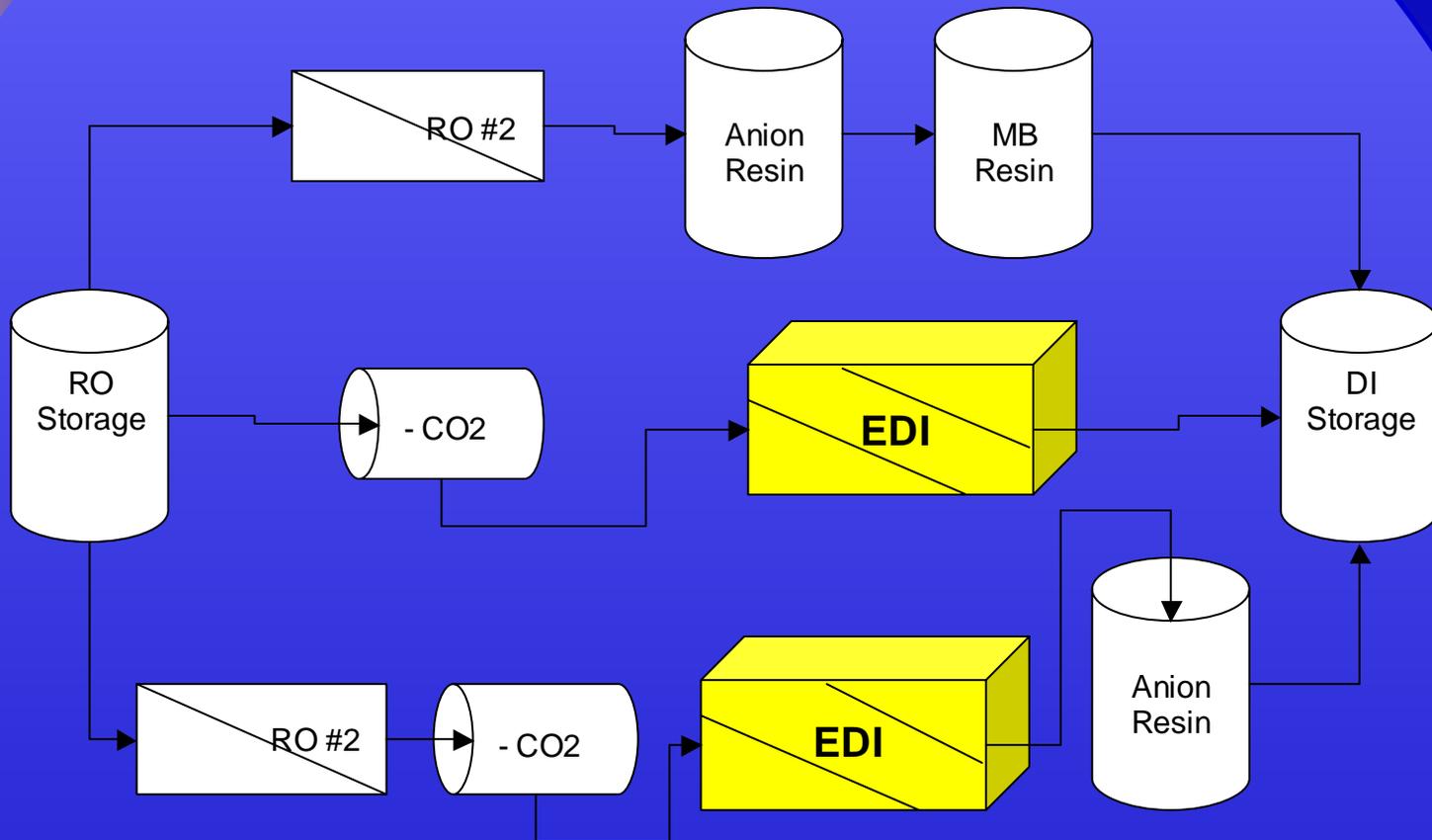
# 1 : RO & 前 (Pretreatment)





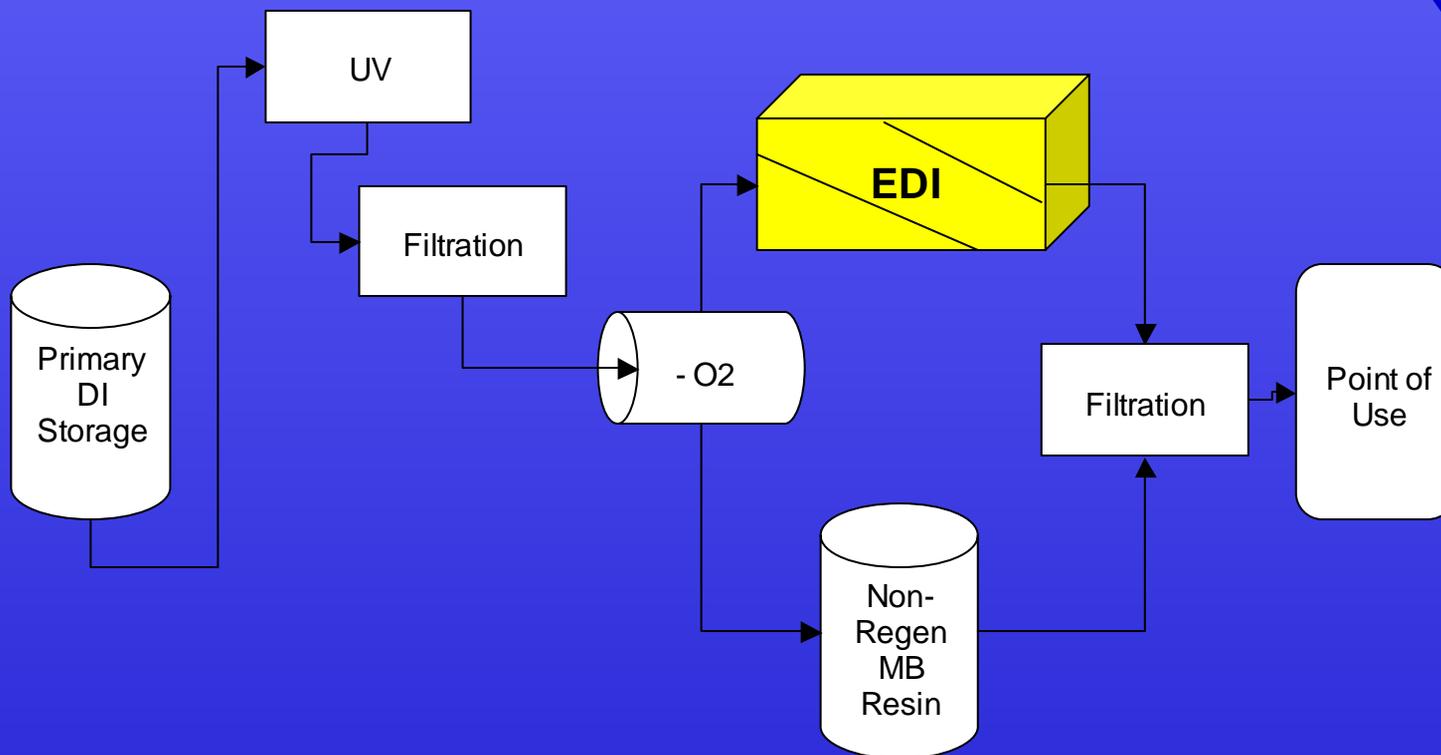
## 2 : Primary DI System Options

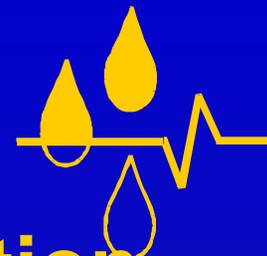
( DI )





### 3 : Polishing DI System Options( )





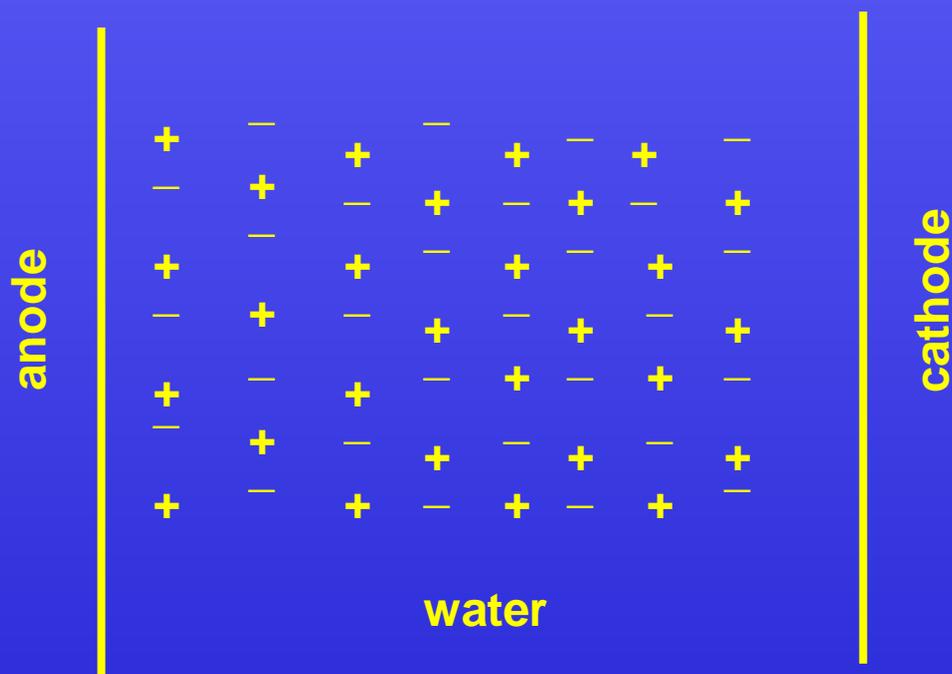
# Introduction: EDI Electro Deionization

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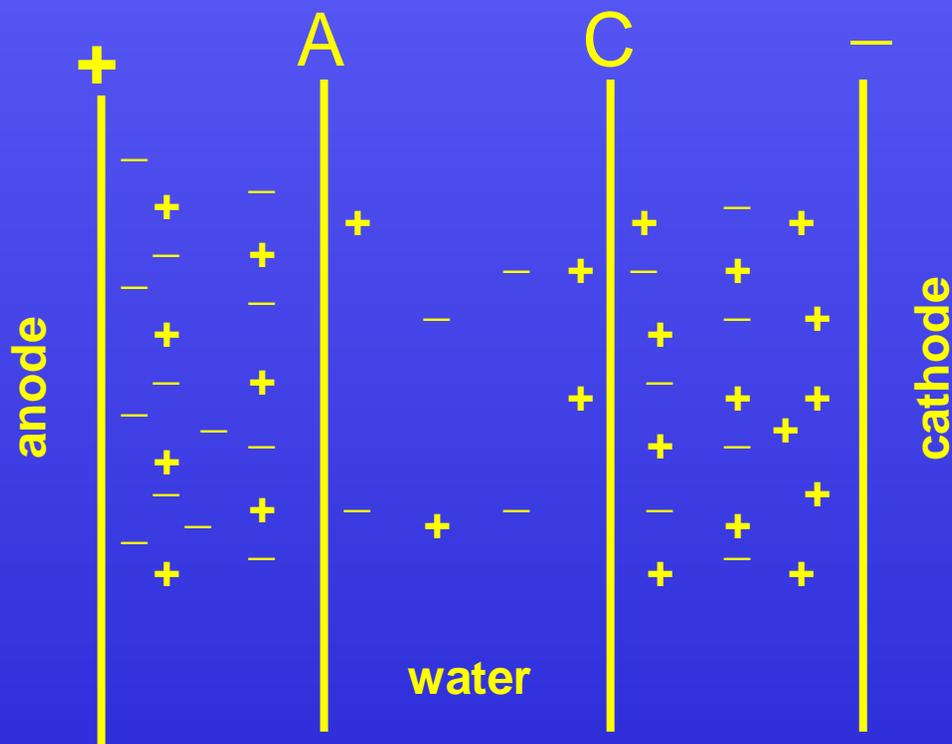


# ED Electro-Dialysis





# ED Electro-Dialysis





# ED (ED limitations for Deionizing Water)

- ✧ 가
- ✧ ( )
- ✧ ED module



# ED transforms into EDI(ED EDI )



:



가 .



:

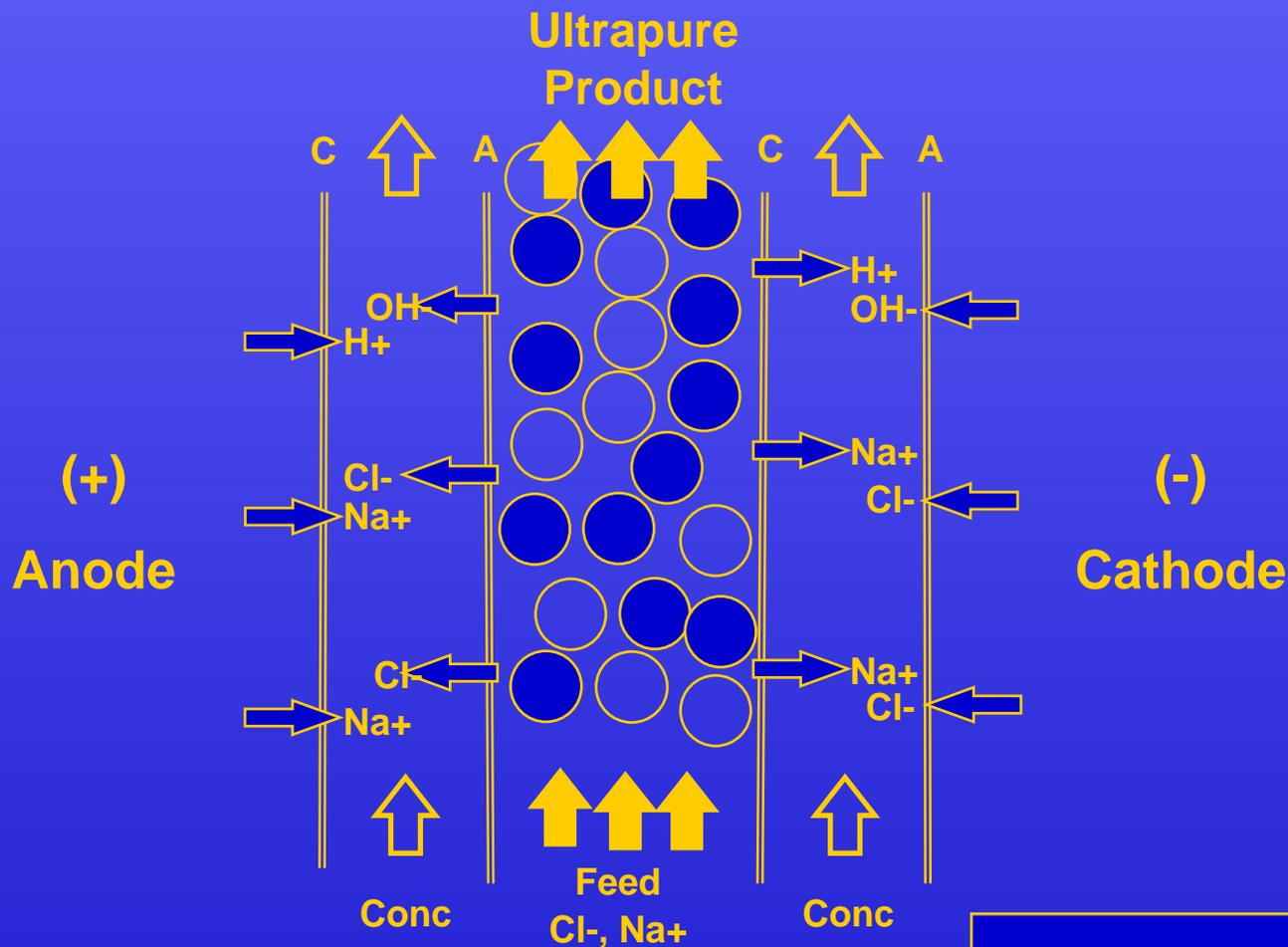
■ IX Resins( ) 가  
100

■ IX Resins( ) 가

■ IX Resins( ) 가 H+ OH-  
가 .



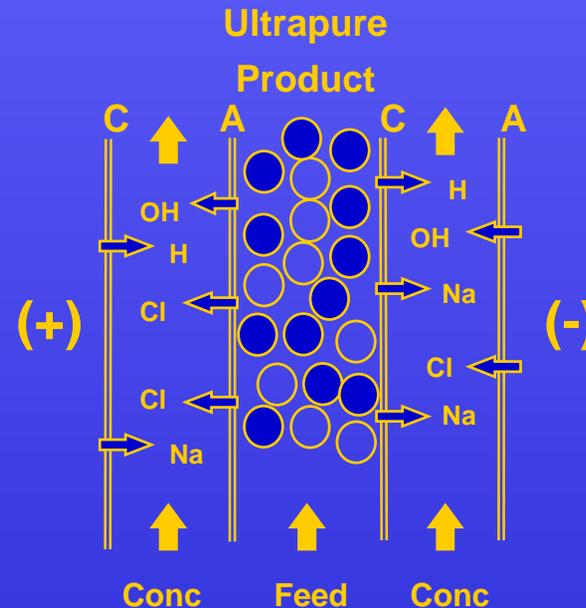
# Electropure EDI Technology

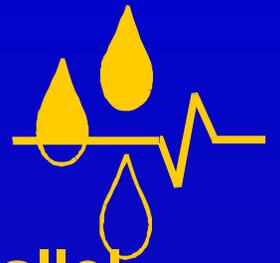




# Electropure EDI Technology

- ◇
- ◇ Resins in Steady State (no regen)
- ◇
- ◇ Upflow design
- ◇
- ◇ Thin cells for better ion removal
- ◇
- ◇ Mixed bed resins for best silica removal

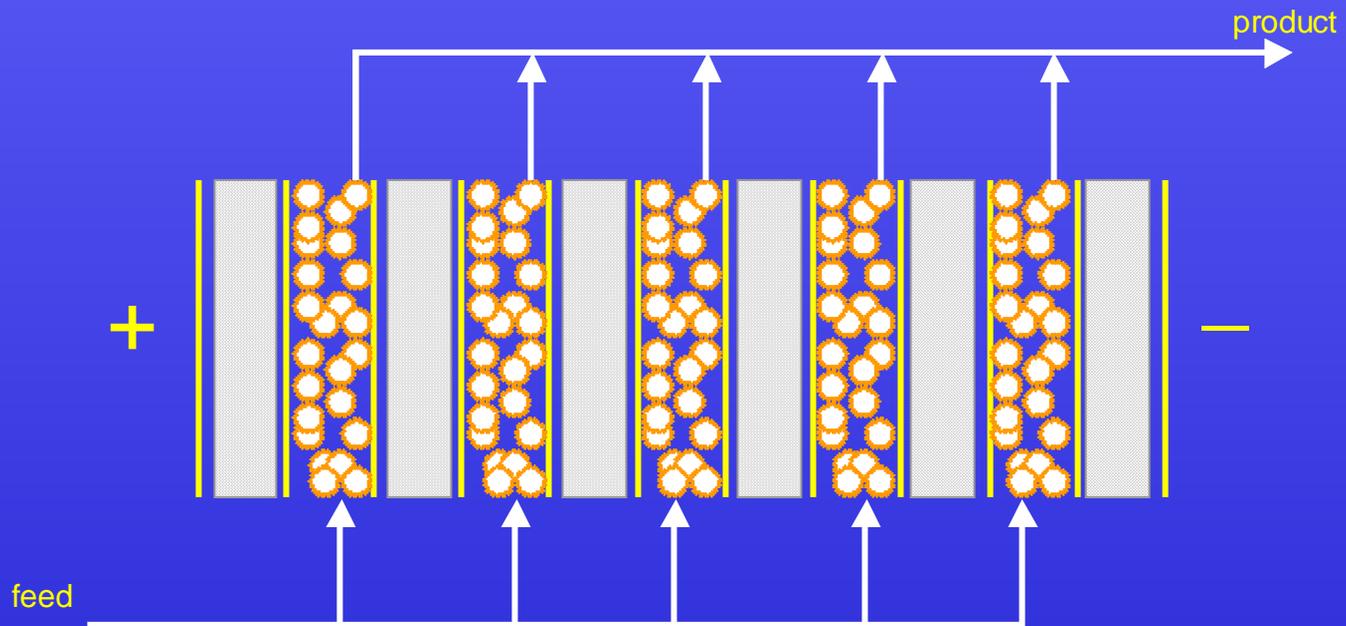




EDI Module:

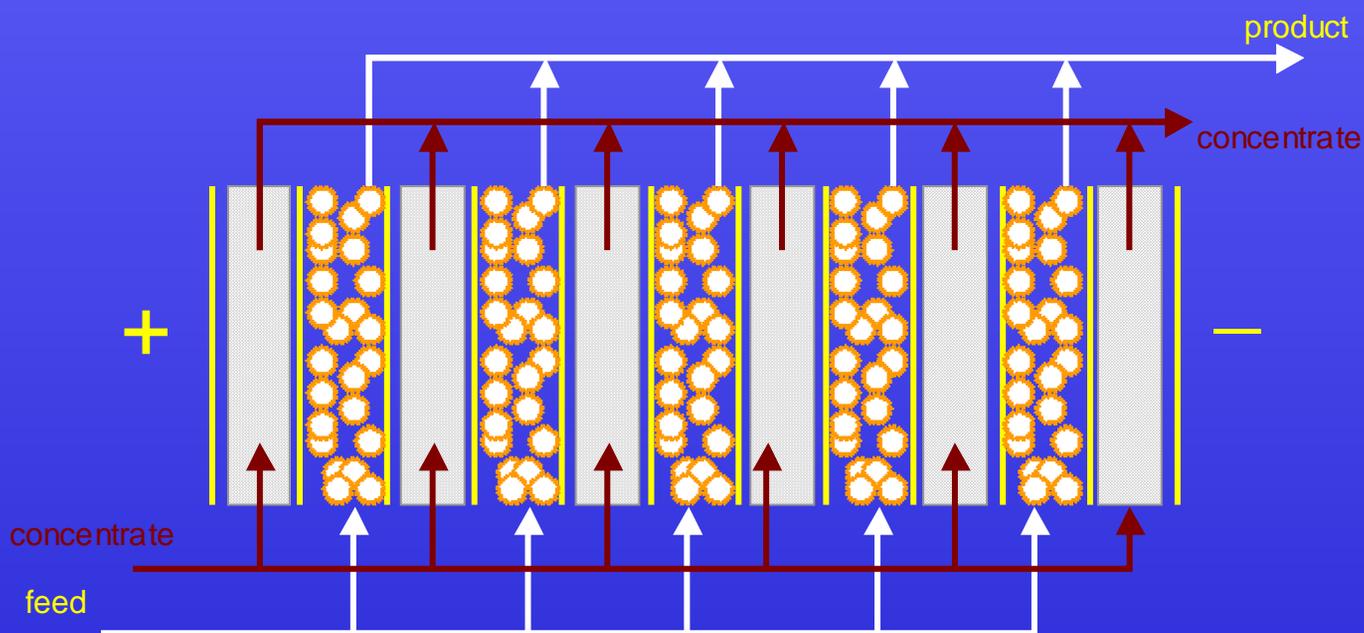


multiple cells in parallel



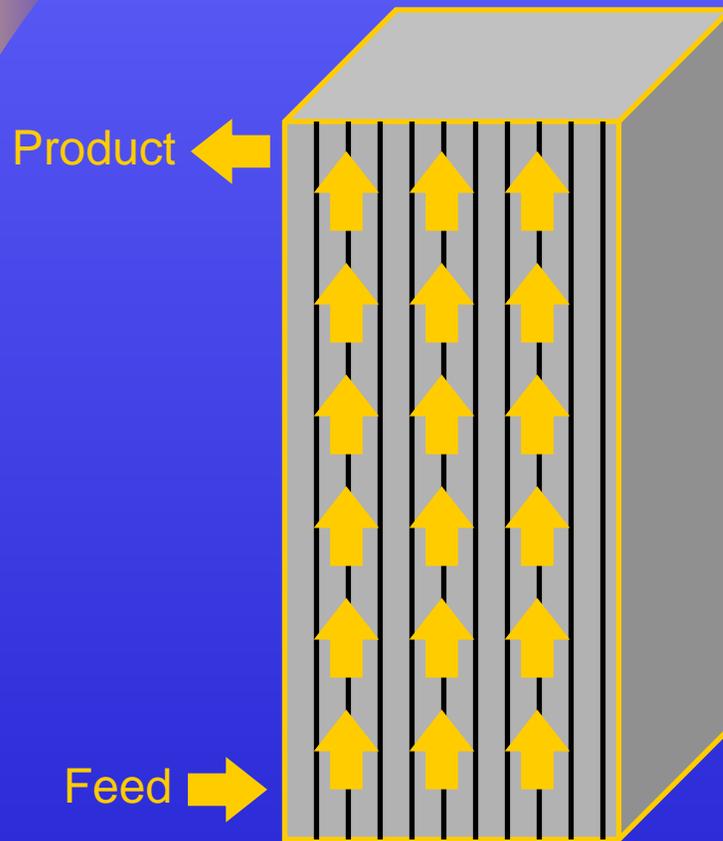


## EDI Module: multiple cells in parallel



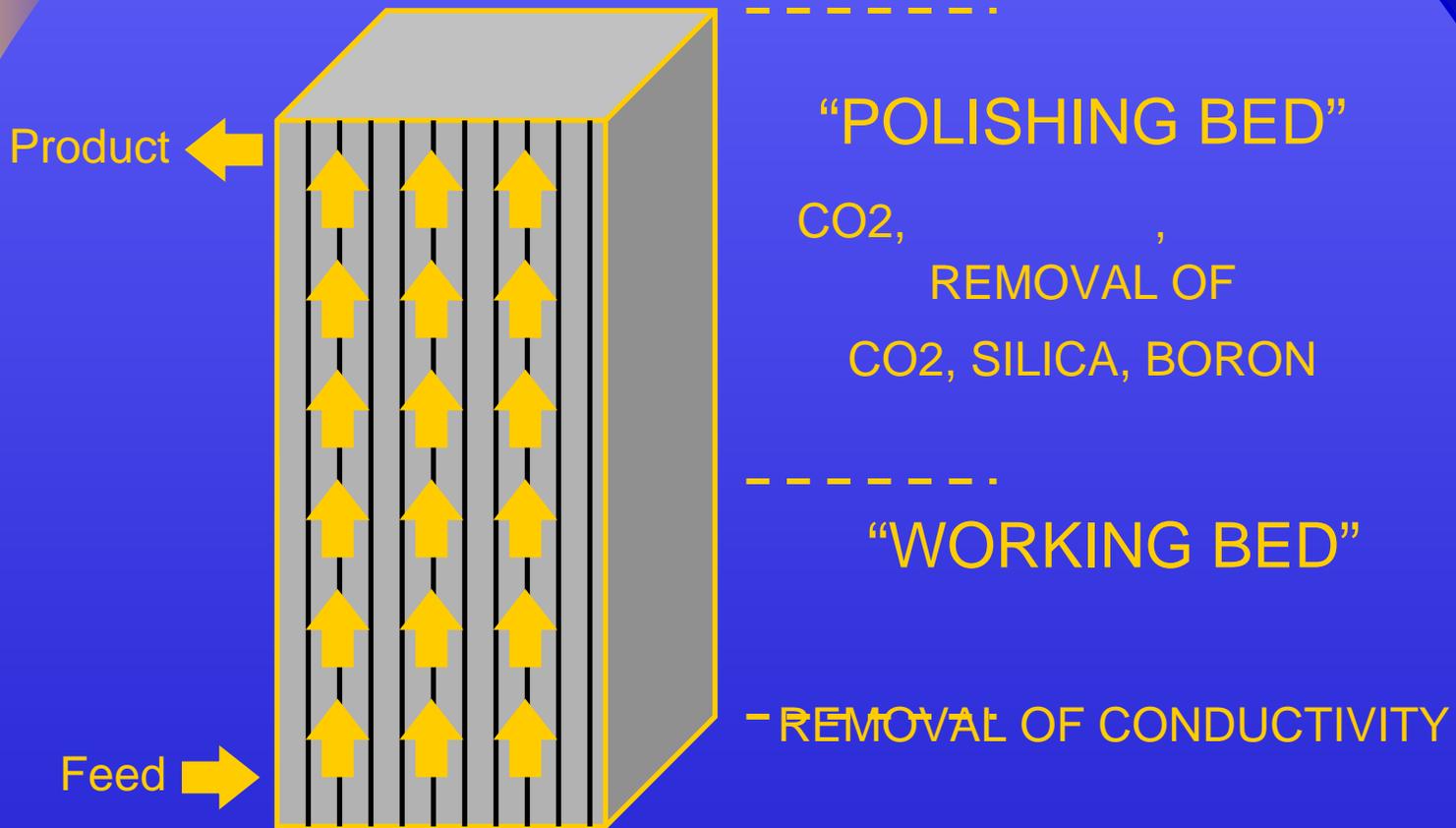


# XL by Electropure™





# EDI Technology





# XL by Electropure™



- ◇ :  
가
- ◇ 가
- ◇
- ◇
- ◇ 18,1Megohm.Cm  
가



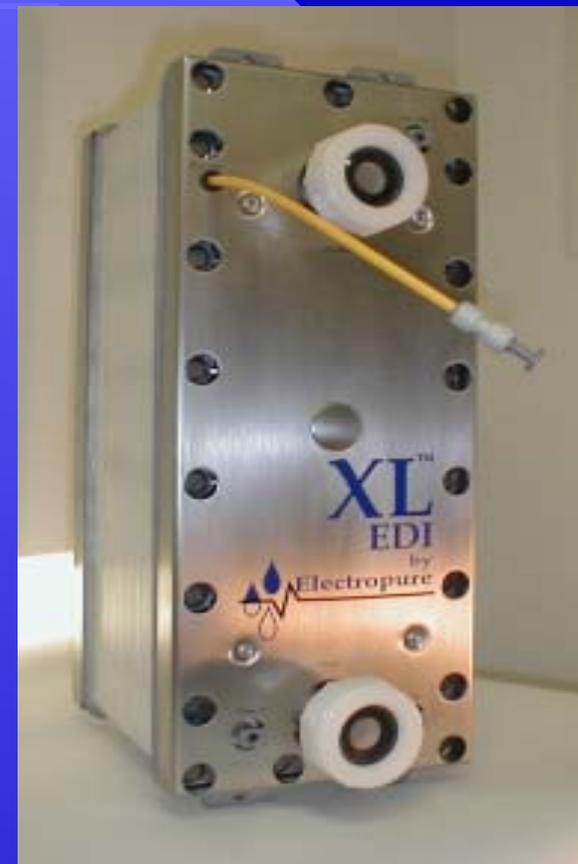
# EDI Module



XL-500



XL-100-S



XL-500-HTS



# XL by Electropure™



가





# XL by Electropure™

## Product Flow

<b>XL-500</b>	1,3-2,3 m <sup>3</sup> /h
<b>XL-400</b>	0,7-1,5 m <sup>3</sup> /h
<b>XL-300</b>	300-900 l/h
<b>XL-200</b>	100-300 l/h
<b>XL-100</b>	50-150 l/h



# EDI Systems

◇ 100 m<sup>3</sup>/  
가

◇ RO

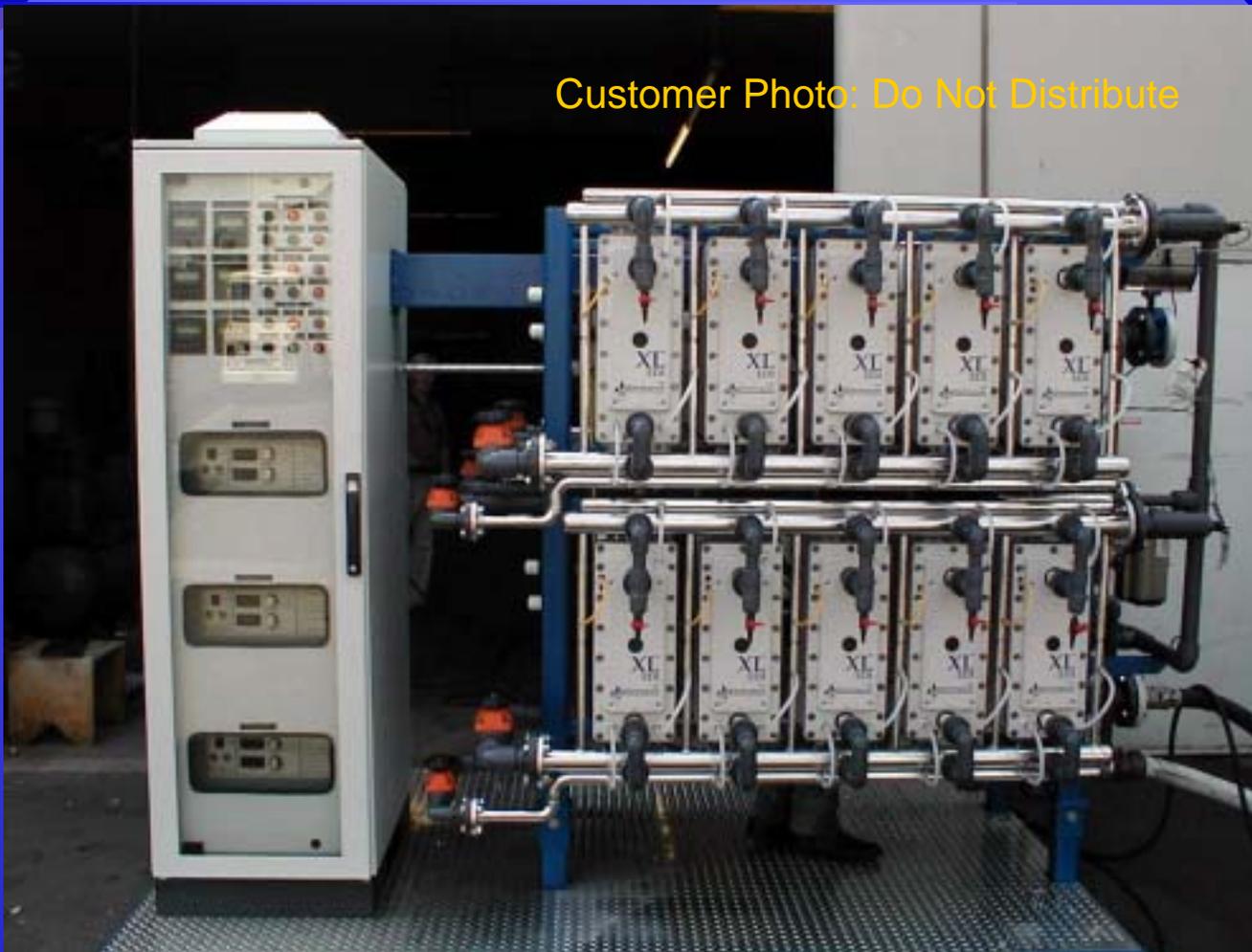
가



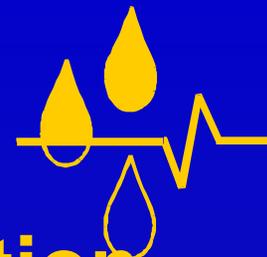


## 150 gpm Semiconductor System

Customer Photo: Do Not Distribute



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# Introduction: EDI Electro Deionization

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# EDI가 가

- ◇ “ ”  
“Easy” ions in feedwater
  - $\text{Na}^+$ ,  $\text{Cl}^-$ , .
- ◇ Fewer ions in feedwater
- ◇ Proper voltage driving force
  - 
  - depends on %recovery and temperature
- ◇ , , ,  
No oxidizers, no metals, no debris, no organics (TOC)
- ◇ Good internal pressure balance
- ◇ Proper and Simple system design



**EDI Performance:**

**Conductivity**

✧ XL Performance: 17.0-17.5  
Megohm.cm

✧ XL Field Performance: 17.9-  
18.1 Megohm.cm

✧ Reduces Ion Load on Mixed Bed  
Polisher

✧ **Keys**  
to Performance....

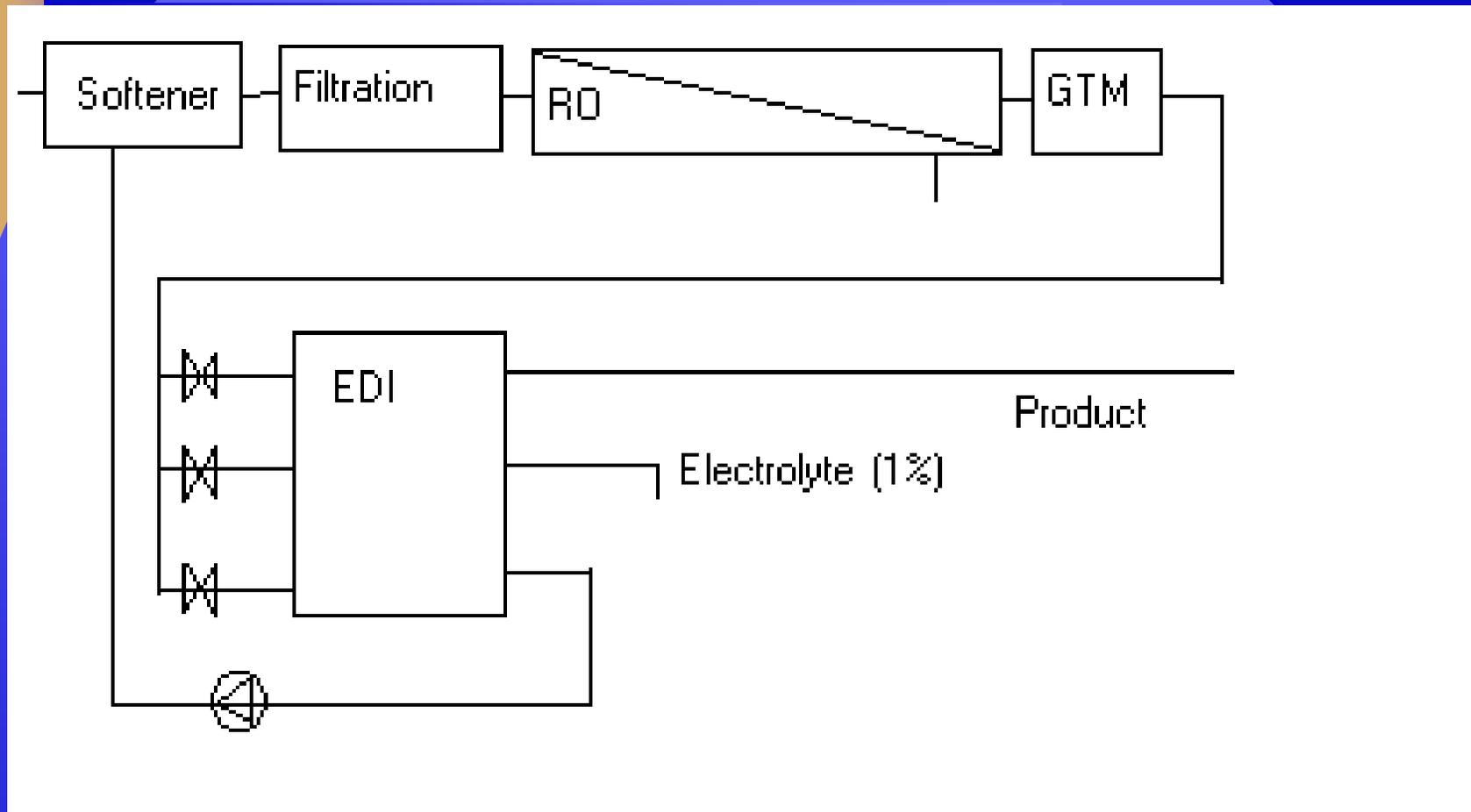


## Keys to EDI Performance

- ◇ 前 Proper Pretreatment
- ◇ Proper Feedwater
- ◇ Constituents
- ◇ 5 ppm CO<sub>2</sub>
- ◇ Agents Minimum Oxidizing
- ◇ Periodic Torqueing



## Simple System Design





## Silica Numbers

- ✧ RO Feed: 5-70 ppm
- ✧ RO Silica (Rejection): 99.7% per Hydranautics (CPA4: 2x Chloride)
- ✧ Silica EDI (Inlet Maximum): 0.5 ppm
- ✧ 20 ppm - 99% System - 0.2 ppm to EDI
- ✧ XL: 88-92% by Hach 5000 with 200 ppb feed
- ✧ .... 20 ppb feed to MB polisher
- ✧ .... 1-3 ppb from MB polisher



EDI

가?

- ◇ (O<sub>3</sub>, Cl<sub>2</sub>)
- ◇ 가 (Fe<sup>+3</sup>, Mn)
- ◇ 高 ( )
- ◇ ( )
- ◇ “가 ” 가 SiO<sub>2</sub>, CO<sub>2</sub>
- ◇ ( )
- ◇ 高 硬軟 ( )



# EDI

◇ : 3

◇ :

■ “RO 前 ”

◇ : 7-8



# EDI

# ?



- EDI RO
- 
- EDI 1
- 
- CO<sub>2</sub>
- SiO<sub>2</sub>
- /
- /



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